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RESPONSE UNDER 37 C.F.R. 1.116
EXPEDITED PROCEDURE
EXAMINING GROUP 2823

#10/D
3/1/01
Bell

AF/2823
PATENT



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Goldberg (TI-25588)

Serial No. 09/085,298 ✓

Group Art Unit: 2823

Filed: May 27, 1998

Examiner: K. Eaton

For: Method for Thermal Nitridation and/or Oxidation of Semiconductor Surface and Related
Processing Equipment

AMENDMENT UNDER RULE 116

Assistant Commissioner for Patents

Washington, DC 20231

Dear Sir:

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In response to the Office Action mailed October 11, 2000, entry of the following amendment in, and reconsideration of, the above-referenced application, are respectfully requested.

In the claims:

Amend claim 8 as follows:

OK
W. C. 3/5/01

8 (amended). The method of claim 7, wherein said bottom structure is a silicon substrate and said top structure is a gate structure[;].

01